ECR ION SOURCES

ACTIVITY DESCRIPTION

The GANIL Ion Source staff has been developing their expertise in the domain of ECR (Electron Cyclotron Resonance) ion sources for 35 years; they took out a first patent (CEA & CNRS) for an ECR ion source in 1991. They have also developed numerous methods for metallic ion beam production, are experts in 3D electromagnetic simulations and in the design of high temperature devices.

PERMANENT STAFF

5 researchers/engineers
7 technicians
EQUIPMENT

- 6 ECR ion sources at the GANIL-SPIRAL2 facility
- 1 ECR ion sources at the ARIBE facility

VALORISATION & TECHNOLOGY TRANSFER

- Creation of the PANTECHNIK company in 1991 (GANIL spin-off)
- Patent license agreement with PANTECHNIK for these 5 patents
- 2 R&D collaboration agreements with PANTECHNIK

VARIOUS VALORISATION POTENTIALITIES

- Technology transfer
- R&D collaboration agreements
- Ion source expertise for accelerator projects (scientific, hadrontherapy) and application projects
- Test benches available for measurements, characterisations, R&D